

Line Number	Hits	Search Text	DB	Time stamp
1	57	(glass same photor sist sam (insulat\$ or dielectric)) and (field sam (missin r mitter) same display) and 313/\$.ccls.	USPAT	2003/05/26 08:43
3	5	(glass same ph tor sist sam (insulat\$ or dielectric)) and (field same (emission or emitter) same display)	EP ; JPO; DERWENT; IBM_TDB	2003/05/26 08:41
2	650	(glass same photoresist same (insulat\$ or dielectric))	EPO; JPO; DERWENT; IBM_TDB	2003/05/26 08:42
4	118	(glass same photoresist same (insulat\$ or dielectric)) and display	EPO; JPO; DERWENT; IBM_TDB	2003/05/26 08:43
5	117	(glass same photoresist same (insulat\$ or dielectric)) and 313/\$.ccls.	USPAT	2003/05/26 08:44
6	67	(glass same photoresist same (insulat\$ or dielectric)) and 313/\$.ccls. and plasma	USPAT	2003/05/26 08:44
7	728	glass same photoresist same containing	USPAT	2003/05/26 08:45
8	205	glass same photoresist same containing same (dielectric or insulating)	USPAT	2003/05/26 08:45
9	128	(glass same photoresist same containing same (dielectric or insulating)) and display	USPAT	2003/05/26 08:46
10	7	(glass same photoresist same containing same (dielectric or insulating) same paste) and display	USPAT	2003/05/26 08:48
11	19	(glass same photoresist same (dielectric or insulating) same paste) and display	USPAT	2003/05/26 08:52
12	0	(glass same photoresist same (dielectric or insulating) same paste) and display	EPO; JPO; DERWENT; IBM_TDB	2003/05/26 08:52
13	9	(glass same photoresist same (dielectric or insulating) same paste)	EPO; JPO; DERWENT; IBM_TDB	2003/05/26 08:53
14	66	glass same photoresist same paste	EPO; JPO; DERWENT; IBM_TDB	2003/05/26 08:53
15	24	(glass adj paste) same photoresist	EPO; JPO; DERWENT; IBM_TDB	2003/05/26 10:16
16	6	((glass adj paste) same photoresist) and 445/\$.ccls.	USPAT	2003/05/26 08:57
17	1	6337533.pn. and current	USPAT	2003/05/26 10:19
18	0	6337533.pn. and force	USPAT	2003/05/26 10:20
19	1	6337533.pn. and press\$	USPAT	2003/05/26 10:24
20	12	445/\$.ccls. and (resistance adj (w ld or w lding)) and (las r adj (w ld r w lding)) and (spark adj plug)	USPAT	2003/05/26 10:26

21	4	445/\$.ccls. and (resistance adj (weld or welding)) and (laser adj (weld or welding)) and (spark adj plug) and (current same (time or speed or supply or amount or length))	USPAT	2003/05/26 10:31
22	0	(resistance adj (weld or welding)) and (laser adj (weld or welding)) and (spark adj plug) and (current same (time or speed or supply or amount or length))	USOCR	2003/05/26 10:31
23	25	(resistance adj (weld or welding)) and (laser adj (weld or welding)) and (spark adj plug) and (current same (time or speed or supply or amount or length))	USPAT; US_PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/26 10:48
24	0	GB2306196	EPO; JPO; DERWENT; IBM_TDB	2003/05/26 10:48
25	5	"2306196"	EPO; JPO; DERWENT; IBM_TDB	2003/05/26 10:48